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(54) Title (EN): COSMETIC COMPOSITIONS AND METHODS OF USE

(54) Title (FR): COMPOSITIONS COSMÉTIQUES ET PROCÉDÉS D'UTILISATION

(57) Abstract:

(EN): The present invention relates to substituted stilbenes and dienones which exhibit unexpected dual activity, as inhibitors of NFκB and as agonists (activators) of Nrf2. In particular, these compounds show dual activity and it has been discovered that these compounds are particularly useful in the treatment of certain cosmetic applications and in rejuvenating and beautifying skin and other keratinous tissue of a subject in need. Cosmetic compositions and methods of using said compositions in combination with other components are disclosed herein.

(FR): La présente invention concerne des stilbènes et des diénones substitués qui présentent une double activité inattendue, en tant qu'inhibiteurs de NFκB et en tant qu'agonistes (activateurs) de Nrf2. En particulier, ces composés présentent une double activité et il a été découvert que ces composés sont particulièrement utiles dans le traitement de certaines applications cosmétiques et pour rajeunir et embellir la peau et d'autres tissus kératiniques d'un sujet qui en a besoin. L'invention concerne également des compositions cosmétiques et des procédés d'utilisation desdites compositions en combinaison avec d'autres éléments.

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